

Title (en)

METHOD AND APPARATUS FOR PROCESSING A MICROELECTRONIC WORKPIECE AT AN ELEVATED TEMPERATURE

Title (de)

VERFAHREN UND VORRICHTUNG ZUR VERARBEITUNG EINES MIKROELEKTRONISCHEN WERKSTÜCKS BEI HOHEN TEMPERATUREN

Title (fr)

DISPOSITIF ET PROCEDE DE TRAITEMENT A TEMPERATURE ELEVEE D'UNE PIECE OUVREE DE MICRO-ELECTRONIQUE

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Application

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Abstract (en)

[origin: WO0159815A2] An apparatus and method for processing a microelectronic workpiece at an elevated temperature. In one embodiment, the apparatus includes a workpiece support positioned to engage and support the microelectronic workpiece during operation. The apparatus can further include a heat source having a solid engaging surface positioned to engage a surface of the microelectronic workpiece with at least one of the heat source and the workpiece support being movable relative to the other between a first position with the microelectronic workpiece contacting the engaging surface of the heat source and a second position with the microelectronic workpiece spaced apart from the engaging surface. The heat source is sized to transfer heat to the microelectronic workpiece at a rate sufficient to thermally process a selected material of the microelectronic workpiece when the microelectronic workpiece is engaged with the heat source. A heat sink can be positioned at least proximate to the heat source to cool both the heat source and the microelectronic workpiece.

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